


FORM 1449* INFORMATION DISCLOSURE STATEMENT IN AN APPLICATION (Use several sheets if necessary)	Docket Number: 12052.17USD2	Application Number: Unknown
	Applicant: KOYAMA, et al.	
	Filing Date: Herewith	Group Art Unit: Unknown

U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
JJ	5,691,792	November, 1997	Mizushima, et al.				
	5,607,732	March, 1997	Miyamoto, et al.				
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
JJ	JP 8-508207	09/03/96	Japan			Abstract	
	JP 8-057678	03/05/96	Japan			Abstract	
	JP 8-025045	03/13/96	Japan			Abstract	
	JP 8-009794	01/31/96	Japan			Abstract	
	JP 7-168023	07/04/95	Japan			Abstract	
	JP 7-102470	11/08/95	Japan			Abstract	
	JP 7-051400	06/15/95	Japan			Abstract	
	JP 7-4675	01/25/95	Japan			Abstract	
	JP 5-303916	11/16/93	Japan			Abstract	
	JP 5-200577	08/10/93	Japan			Abstract	
	JP 4-253583	09/09/92	Japan			Abstract	
	JP 50-42499	04/17/75	Japan			Abstract	
	DE 43 38 969	09/19/96	Germany			Abstract	
	EP 629 592	02/12/94	EPO			Abstract	
	WP 94/04744	03/03/94	PCT				
	EP 0682 272	11/15/95	EPO				
	DE 195 44 295	6/5/97	Germany				
	OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)						
JJ	1993	Yablonovitch, E., "Photonic band-gap structures" <i>J. Opt. Soc. Am.</i> , vol. 10, no. 2, February 1993					
	1996	Tyan, Rong-Chung, Pang-Chen Sun, Axel Scherer and Yeshayahu Fainman, "Polarizing beam splitter based on the anisotropic spectral reflectivity characteristic of form-birefringent multi-layer gratings", <i>Optics Letters</i> , Vol. 21, no. 10, May 15, 1996.					
	1981	Murahara, Masataka; Yoshiyuki Kawamura; Koichi Toyoda, and Susumu Namba, "Fabrication of PMMA Holographic Grating by KrF Excimer Laser", December 14, 1981					
	1996	Holmer, Anna-Karin, Simultaneous Machining of Parallel Grooves in SnO ₂ Thin Films Using a ND:YAG Laser and a Kinoform, May 20, 1996, pp. 2614-18, <i>Applied Optics</i> , Vol. 35, No. 15					

EXAMINER	DATE CONSIDERED 3/10/05	 23552 PATENT TRADEMARK OFFICE
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.		